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Correction: Electronic properties of antimony-doped anatase TiO₂ thin films prepared by aerosol assisted chemical vapour deposition

Davinder S. Bhachu,^a Tomos G. A. A. Harris,^a Russell G. Egde^b,
Gopinathan Sankar,^a Claire J. Carmalt^a and Ivan P. Parkin^{*a}

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The authors regret the omission of author Tomos G. A. A. Harris from the original author list. The correct author list is as above. The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

^a Materials Chemistry Centre, Department of Chemistry, University College London, 20 Gordon Street, London WC1H 0AJ, UK. E-mail: i.p.parkin@ucl.ac.uk; Fax: +44 20-7679-7463

^b Department of Chemistry, University of Oxford, Inorganic Chemistry Laboratory, South Parks Road, Oxford OX1 3QR, UK

